

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):	Jack O. Chu, et al.	Examiner:	Unassigned
Serial No:	To be assigned	Art Unit:	Unassigned
Filed:	Herewith	Docket:	YOR920010308US2 (16315A)
For: EPITAXIAL AND POLYCRYSTALLINE GROWTH OF $\text{Si}_{1-x}\text{yGe}_x\text{Cy}$ AND Si_{1-y}Cy ALLOY LAYERS ON Si BY UHV-CVD		Dated: February 10, 2004	

Commissioner for Patents
United States Patent Office
Alexandria, VA 23313-1450

PRELIMINARY AMENDMENT

Sir:

In connection with filing the above-identified application under 37 C.F.R. §1.53(b), applicants submit the following amendments and remarks for consideration by the Examiner and entry of record in the above-identified patent application.

CERTIFICATE OF MAILING BY "EXPRESS MAIL"

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I hereby certify that this correspondence is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 C.F.R. § 1.10 on the date indicated above and is addressed to the Commissioner for Patents and Trademarks, Alexandria, VA 22313-1450 on February 10, 2004.

Dated: February 10, 2004



Leslie S. Szivos, Ph.D.